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Title: Master plate for fabricating a stamper plate, stamper plate, storage medium, and method for fabricating the master plate, stamper plate and storage medium.

This invention relates to a master plate for fabricating a stamper plate for production of an optical storage medium with information such as a CD or a DVD, the master plate comprising a substrate and a photoresist layer applied thereto, while parts of the photoresist layer exposed to light of a predetermined frequency are soluble in a solvent.

5 The invention further relates to a stamper plate for the production of an optical storage medium with information, and to the optical storage medium as such.

10 In addition, the invention relates to a method for fabricating a master plate for fabricating a stamper plate, wherein a photoresist layer is applied to a substrate, while parts of the photoresist layer exposed to light of a predetermined frequency are soluble in a solvent.

Furthermore, the invention relates to a method for fabricating a stamper plate and an optical storage medium.

15 Such master plate and such method are known from practice. For the fabrication of the known master plate according to the known method, first an adhesive such as n-(2-amino-ethyl)-3-aminopropyl-trimethoxysilane is applied to the substrate. Next, the adhesive is rinsed with a rinsing agent such as water. This rinsing period is some 30 seconds. According to the prior
20 art, the adhesive layer is applied as thinly as possible, on the assumption that this is required to accomplish a firm adhesion to the photoresist layer to be subsequently applied. By rinsing, the excess adhesive is removed, the intention being to realize an adhesive layer of just a few nanometers (monolayer) on the substrate. Next, the photoresist layer is applied onto the
25 adhesive layer. After this, it is possible to expose parts of the photoresist layer according to a predetermined pattern to light of the predetermined

frequency. As a result, the solubility of the exposed parts in the solvent increases strongly. By rinsing the photoresist layer with the solvent, the exposed parts of the photoresist layer are removed. This yields a relief pattern such as a hole pattern in the photoresist layer, this relief pattern 5 corresponding, for instance, to digital information to be subsequently transferred to an optical medium via a stamper plate manufactured with the master plate. Finally, the surface of the photoresist layer of the master plate can be provided with a relatively thin metal layer by which the surface is rendered conductive. In this connection, it is noted that relatively thin is 10 understood to mean that the relief pattern preserves the digital information.

The master plate can be used for fabricating a so-called stamper plate. The metal layer applied to the master plate is, for instance, a nickel layer which makes it possible for the master plate to serve as a cathode in a galvanic process. In this process, a stamper plate is formed as a negative 15 copy of the master plate by means of cathodic deposition of nickel in a box filled with nickel spheres which functions as an anode. Since the stamper plate is a negative copy of the master plate, the stamper plate has a relief pattern whose protrusions correspond to recesses of the relief pattern of the master plate. When the relief pattern of the master plate is a hole pattern, 20 the relief pattern of the stamper plate is a pattern of posts which correspond to the holes of the hole pattern. The thus fabricated stamper plate can subsequently be used in an injection mold for the production of optical storage media with information, such as CDs or DVDs. The hole pattern is thereby transferred via the stamper plate to the optical storage media and 25 comprises the information referred to.

A first aspect of the present invention is the recognition that a stamper plate manufactured with the known master plate is not self-clearing relative to optical media to be manufactured therewith. One of the causes of this is that in the manufacture of the known master plate the 30 photoresist layer tends to lift from the substrate during rinsing with the

solvent. Another cause is that the solvent etches away too much material of the photoresist layer, chiefly at the bottom of the holes near the substrate. The result is that the protrusions such as the above-mentioned posts of the stamper plate fabricated with the master plate have barbs. This has as a 5 consequence that optical storage media manufactured with the stamper plate suffer from the phenomenon of "clouding", as will be elucidated in more detail hereinafter. Due to the stamper plate having protrusions with barbs, the polycarbonate material of the optical media will have difficulty coming off the stamper plate after injection molding. It is possible that as 10 the media are pulled off the stamper plate, material of the optical media will be torn loose. This is the phenomenon of "clouding". A first consequence is that the fabricated media do not look esthetic, which makes the phenomenon of clouding visible. This is manifest in an annular pattern (which may or may not be local) on the mirroring surface of the master 15 plate. A second consequence is that the stored information deforms or is actually lost.

It is a second aspect of the invention to provide a solution to the problem signaled above. In particular, it is an object of the invention to provide a master plate whose relief pattern can yield a stamper plate which 20 is self-clearing relative to optical media to be manufactured therewith. To this end, the invention provides a master plate characterized in that the solubility exhibits a trend along the normal to the photoresist layer, with the solubility on the side near the substrate being less than the solubility on the opposite, upper side of the photoresist layer. Accordingly, there is a 25 gradient in the solubility of exposed parts of the photoresist layer. This means that upon rinsing with the solvent, exposed parts at the upper side of the photoresist layer are dissolved relatively fast and rinsed off, after which exposed parts of the photoresist layer near the substrate are dissolved relatively slowly and rinsed off. The result is that the bottom of each of the 30 recesses or holes of the relief pattern obtains a flowing contour. As a result,

the protrusions (posts) of the stamper plate corresponding to the recesses (holes) are substantially free from barbs. This means that the production of the optical media can take place without entailing appreciable clouding.

According to a preferred embodiment, the photoresist layer has a
5 first subphotoresist layer which is provided on the substrate, by way of an adhesive layer or not, and a second subphotoresist layer which is provided on the first subphotoresist layer, the solubility in the solvent of exposed parts of the first subphotoresist layer being less than the solubility in the solvent of exposed parts of the second subphotoresist layer. Here, the
10 flowing contour of the bottom of each of the recesses of the master plate is situated near the transition of the first and the second subphotoresist layer.

Exposing parts of the photoresist layer can be done using laser light of a frequency in the frequency band of 200-500 nm. Further, the solvent can be an alkaline solvent.

15 The method according to the invention is characterized in that the photoresist layer is provided by applying a first material and a second material onto the substrate, such that the solubility of the photoresist layer on the side near the substrate is less than the solubility on the opposite, upper side of the photoresist layer.

20 According to a preferred embodiment of the method according to the invention, the method comprises the following steps:

- providing a first subphotoresist layer on a substrate, wherein exposed parts of the first subphotoresist layer have a first solubility in a solvent;
- 25 • providing a second subphotoresist layer on the first subphotoresist layer, wherein exposed parts of the second subphotoresist layer have a second solubility in the solvent, and wherein the second solubility is greater than the first solubility.

This method can be carried out, for instance, by providing an
30 adhesive layer of an adhesive such as n-(2-amino-ethyl)-3-aminopropyl-

trimethoxysilane directly on the substrate, after which a photoresist layer is provided on the adhesive layer. Optionally, between applying the adhesive layer and the subsequent application of the photoresist layer, rinsing is done with a rinsing agent such as water for a short time of, for instance,

5 seconds. Preferably, however, rinsing is not done at all. As a consequence, the adhesive layer applied according to the invention is relatively thick. The thickness of the adhesive layer can be, for instance, 30-40 nanometers. The photoresist layer applied to the relatively thick adhesive layer appears to enter into a crosslinking reaction with the adhesive of the relatively thick
10 adhesive layer, whereby molecules of the adhesive diffuse into the photoresist layer. Through the crosslinking reaction, the adhesive layer turns into a subphotoresist layer, exposed parts of which have a relatively low solubility in the solvent. The new subphotoresist layer can be formed from the adhesive layer owing to the adhesive layer being relatively thick.
15 Thus, with this method, a master plate can be manufactured, in which on the substrate of the master plate a first subphotoresist layer having a first solubility in the solvent after exposure has been formed, and in which on the first subphotoresist layer there is a second subphotoresist layer having a second solubility. What applies here is that the first solubility is less than
20 the second solubility. It has also been found that the subphotoresist layers have obtained a firm bond with each other and the substrate.

According to the prior art, a relatively long rinsing period for rinsing of the adhesive is required for obtaining a relatively thin adhesive layer for a proper bonding to the photoresist layer to be subsequently applied. According to the invention, however, omitting this rinsing step has been found to yield a particularly effective and simple method for fabricating a self-clearing master plate, while further an adequate bonding of the photoresist layer is achieved.

According to an alternative embodiment of the method according
30 to the invention, on the substrate a subphotoresist layer is provided which is

subjected to a curing treatment. The curing treatment can consist in, for instance, irradiation with ultraviolet light of a predetermined frequency, or a heat treatment. As a result of the curing treatment, the solubility after exposure of the photosensitive layer in the solvent (as described hereinbefore) decreases definitively. Subsequently, on the cured first subphotoresist layer, the second subphotoresist layer having the second solubility can be provided, the second solubility being greater than the first solubility of the cured subphotoresist layer.

10 The invention will presently be elucidated in more detail with reference to the drawing, in which:

Figs. 1a-1d schematically illustrate the method for manufacturing a master plate;

Fig. 2a schematically represents the fabrication of a stamper plate using the master plate according to Fig. 1d;

15 Fig. 2b schematically represents the production of an optical storage medium with information, such as a CD, using a stamper plate included in an injection molding machine;

Fig. 3a schematically shows a part of a master plate according to the prior art with a hole of a hole pattern;

20 Fig. 3b shows a part of a first master plate according to the invention with a hole (recess) of a hole pattern (relief pattern), where the master plate comprises a fully cured first subphotoresist layer and, provided thereon, a second subphotoresist layer;

Fig. 3c shows a part of a second master plate according to the invention with a hole (recess) of a hole pattern (relief pattern), where the master plate comprises a first subphotoresist layer of a first solubility after exposure and a second subphotoresist layer of a second solubility after exposure, the second solubility being greater than the first solubility;

Fig. 4 schematically illustrates in what way an adhesive layer applied to a substrate enters into a crosslinking reaction with a photoresist layer applied onto the adhesive layer.

For manufacturing a master plate 2, an adhesive is applied to a substrate 4. This adhesive forms an adhesive layer 6 on the substrate. Optionally, a part of the adhesive is removed with a rinsing agent such as water, whereby an adhesive layer 6 of a particular thickness is realized. Next, a photoresist layer 8 is applied onto the adhesive layer 6. This photoresist layer 8 can be exposed with the aid of a laser 10. The frequency of the laser light can be in a band of 200-500 nanometers. As a result of the exposure, exposed parts 12.1 and 12.2 are formed in the photoresist layer 8. These exposed parts have a greater solubility in an alkaline solvent (such as sodium hydroxide solution) than the non-exposed parts of the photoresist layer 8. When the photoresist layer 8 according to Fig. 1c is rinsed with the alkaline solvent, a relief pattern is formed, such as a hole pattern with recesses such as holes 14.1 and 14.2 in the photoresist layer (as shown in Fig. 1d). Thus, a predetermined hole pattern can be created in the photoresist layer 8. The hole pattern represents particular digital information. When the photoresist layer 8 is provided with the hole pattern, the substrate with the photoresist layer can serve as master plate 2. Preferably, the surface of the photoresist layer of the master plate 2 is further provided with a relatively thin metal layer (not shown in the drawing). Thus, the master plate can serve as a cathode in a galvanic production process of a stamper plate, as will be elucidated in more detail hereinafter.

With the master plate 2, by a known galvanic process, a stamper plate 16 can be fabricated (Fig. 2a). The stamper plate 16 is a negative copy of the master plate 2. With the aid of the stamper plate 16, subsequently an optical storage medium 20 with information such as a CD or DVD can be produced by an injection molding process in an injection molding machine

18 (Fig. 2b). In this process, with the posts 22.1 and 22.2, which correspond to the holes 14.1 and 14.2, an impression is made in the CD to be formed. The impression thus made corresponds to the hole pattern in the master plate 2 and comprises the transferred digital information.

5 Fig. 3a shows a master plate according to the prior art, which consists of a substrate 4 and a photoresist layer 8 provided thereon. In the photoresist layer, a hole 14 of a hole pattern is provided, it being clear to see that the hole will not yield a stamper plate with posts having a self-clearing capacity. As a result, in the production of the stamper plate, barbs will form
10 on the stamper plate post 22 corresponding to the hole 14. These barbs will be present at the top of the post 22. In the production (Fig. 2b) of the CD, these barbs will result in damages (resulting in the phenomenon of clouding) of the polycarbonate material of the optical medium 20 during the release of the optical medium 20 from the stamper plate 16.

15 Fig. 3b shows a first master plate 2 according to the invention, which comprises a first subphotoresist layer 8.1 and, provided thereon, a second subphotoresist layer 8.2. In this case, the first subphotoresist layer is fully cured, so that the solubility of exposed parts of this subphotoresist layer 8.1 is very minor. The exposed parts of the second subphotoresist layer
20 8.2, however, are relatively well soluble in the solvent. The hole 14 of the master plate 2 according to Fig. 3b has a self-clearing capacity that is greater than the self-clearing capacity of the hole 14 of the master plate 2 according to Fig. 3a.

25 Fig. 3c shows a master plate which comprises two subphotoresist layers 8.1 and 8.2. The exposed parts of the subphotoresist layer 8.1 have a first solubility and the exposed parts of the subphotoresist layer 8.2 have a second solubility in the alkaline solvent. The second solubility is greater than the first solubility. Upon etching (rinsing with the solvent), this results in the shape of the hole 14 of the hole pattern as outlined in Fig. 3c. The
30 shape of the hole pattern represented here has been found to have the best

self-clearing capacity in practice. As a consequence, the master plate according to Fig. 3c is eminently suitable to be used for the fabrication of stamper plates 16, such stamper plates 16 being virtually entirely free from barbs on the posts 22. In practice, optical storage media such as CDs and 5 DVDs formed with such stamper plates prove to be substantially free from the phenomenon of clouding. Further, this yields particularly esthetic optical media.

The depth of the hole 14 in the master plate according to Figs. 3b and 3c is virtually equal to the thickness of the second subphotoresist layer 10 8.2. As a rule, this depth is about 150 nanometers when the master plate is intended for the production of a stamper plate for CDs and 130 nanometers when the master plate is intended for the fabrication of a stamper plate for the production of DVDs. The thickness of the first subphotoresist layer can be, for instance, 30 nanometers.

15 One possible way of manufacturing the master plate 2 according to the invention is the following. On a substrate 4 of, for instance, glass, an adhesive such as n-(2-amino-ethyl)-3-aminopropyl-trimethoxysilane, hexamethyldisilazane (HMDS), or trimethylsilyldiethylamine (TMSDEA) is provided. Optionally, for a short time (for instance 5 seconds), rinsing is 20 done with a rinsing agent such as water. Since rinsing is omitted entirely or done for just a short time, a relatively thick adhesive layer of 30-40 nm is formed on the substrate 4. After this, a photoresist layer is applied onto the adhesive layer. This photoresist layer can be an ordinary photoresist layer. Then, a crosslinking reaction starts between the adhesive and the 25 photoresist layer. After this reaction has taken place, the situation as schematically represented in Fig. 4 arises. On the substrate 4, an adhesive layer 6 of just a few nanometers (monolayer) has formed. Immediately above this layer, as a result of the crosslinking reaction, a (new) first subphotoresist layer 8.1 has formed, exposed parts of which have a first 30 solubility in the alkaline solvent. Above the first subphotoresist layer, a

second subphotoresist layer 8.2 has formed (this second subphotoresist layer 8.2 has the same composition as the initially applied photoresist layer, since this layer has not entered into any reaction with the adhesive). The exposed parts of the second subphotoresist layer 8.2 have a second solubility in the 5 alkaline solvent which is greater than the first solubility. As a result, holes created in the master plate 2 will have a self-clearing profile.

The preceding paragraph shows that by omitting the rinsing of the applied adhesive, in a simple manner a master plate 2 can be fabricated in which the created holes 14 will have a self-clearing profile. Also, the 10 bonding of the subphotoresist layers to the substrate 4 proves to be sufficiently strong. This means that in order to obtain a firm bonding, it is not necessary for the applied adhesive layer to be rinsed intensively with a rinsing agent such as water directly after application onto the substrate.

According to an alternative method, the master plate according to 15 the invention can be obtained by applying a first subphotoresist layer 8.1 onto a substrate 4 in a first step, which layer 8.1 is subsequently cured with a curing treatment. As a result of the curing treatment, the solubility of parts after exposure is reduced definitively. This curing treatment can consist in the complete exposure of the subphotoresist layer 8.1 to a UV 20 light beam. Normally, the frequency of the light of this UV light beam will be different than the frequency of the light of the light beam used for exposing parts of a photoresist layer for increasing the solubility in the solvent (exposure for the purpose of etching). By choosing the frequency and the exposure time of the light for the curing treatment, the first solubility of 25 the first photosensitive resist layer can be regulated. A different curing treatment may consist in subjecting the first subphotoresist layer 8.1 to a heat treatment.

After the curing treatment has taken place, in a second step, on the first subphotoresist layer, a second subphotoresist layer can be applied. 30 Thus, a master plate is obtained which comprises two subphotoresist layers,

of which exposed parts (for the purpose of etching) have different solubilities in the alkaline solvent.

The invention has been discussed on the basis of a few exemplary embodiments, but is not in any way limited to these exemplary 5 embodiments. Diverse variations and modifications also falling within the scope of the invention are conceivable. Of importance is that there be a gradient of solubility of exposed parts of the photosensitive resist layer (or of the photosensitive resist layers) that is perpendicular to the plane of the substrate 4. In this way, upon exposure and etching, a relief pattern with, 10 for instance, grooves, pits, holes and/or other recesses is obtained, in which the recesses are self-clearing. It is possible to provide the master plate according to the invention with many different photoresist layers having different solubilities of exposed parts. Also, it is possible to achieve a particular gradient in solubility by utilizing, in the application of the 15 photoresist layer, a first material with a first solubility after exposure (with a first concentration of photo initiator) and a second material with a second solubility after exposure (with a second concentration of photo initiator other than the first concentration). In addition, the solubility of a (first) applied layer can be definitively reduced by, for instance, brief rinsing with 20 a developer ("pre-dip" treatment).